FORM PTO-1449/A and B (Modified)	APPLICATION NO.:	Unassigned	ATTY. DOCKET NO.: \$1022.81113US00	
INFORMATION DISCLOSURE	FILING DATE:	Herewith	CONFIRMATION NO.: Unassigned	
STATEMENT BY APPLICANT	APPLICANT:	S1022.81113US00		
	GROUP ART UNIT:	Unassigned	EXAMINER: Unassigned	
Sheet 1 of 1				

U.S. PATENT DOCUMENTS

Examiner's Initials	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited	Date of Publication or of issue	
		Number	Kind Code	Document	of Cited Document MM-DD-YYYY	
GM		5,158,907		Fitzgerald, Jr.	10/27/92	
		5,285,086		Fitzgerald, Jr.	02/08/94	
		4,396,929		Ohki et al.	08/02/83	
		US2002/008241	Al	Edmond et al.	01/24/02	
		5,279,687		Tuppen et al.	01/18/94	
1		4,806,996		Luryi	02/21/89	
-		5,981,400		Lo	11/9/99	

FOREIGN PATENT DOCUMENTS

Examiner's Initials	Cite No.	Foreign Patent Document			Name of Patentee or Applicant of Cited	Date of Publication of	Translation
		Office/ Country	Number	Kind Code	Document (not necessary)	Cited Document MM-DD-YYYY	(Y/N)
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OTHER ART — NON PATENT LITERATURE DOCUMENTS

Examiner's Initials	Cite No	Include name of the author (in CAPITAL LETTERS) title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, relevant page(s), volume-issue number(s), publisher, city and/or country where published.	Translation (Y/N)
GIR		French Search Report from French Patent Application No. 03/04152, filed April 3, 2003	
		Patent Abstracts of Japan, vol. 2003, no. 04, April 2, 2003 & JP 2002 359189 A (Mitsubishi Materials Silicon Corp.; Mitsubishi Materials Corp.), December 13, 2002	
V		Patent Abstracts of Japan vol. 011, no. 031)E-475), January 29, 1987 & JP 61 198713 A (Fujitsu Ltd.) September 3, 1986	

EXAMINER	DATE CONSIDERED 6/21/96

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